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PATENT
8007-1114

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicants: Hiroki SATO et al. Confirmation: 6778
Serial No.: 10/588,187 Art Unit: 1762
Filed: August 2, 2006 Examiner: Not assigned
For: ALKOXIDE COMPOUND, MATERIAL FOR THIN FILM FORMATION, AND PROCESS FOR THIN FILM FORMATION

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

November 2, 2006

Sir:

In compliance with Rules 1.97 and 1.98, and in fulfillment of the duty of disclosure under Rule 1.56, included with the attached Form PTO-1449 are copies of the listed documents, which are discussed in the specification of the above-identified application. English language abstracts are provided for the cited Japanese references, and the listed U.S. and European patent documents are equivalents for the cited Korean reference. In view of the abstracts, equivalents, and discussion in the specification, it is respectfully submitted that the requirement for a concise explanation of the relevance of the foreign language references has been satisfied. However, copies of the listed U.S. patent and patent publication are not provided in view of the USPTO waiver of the requirement to do so in applications filed after June 30, 2003.

This Information Disclosure Statement is being submitted within three months of the filing date of the present application;

therefore, no fee is required. The Examiner is courteously requested to initial and return a copy of the Form PTO-1449 to confirm entry into the record and consideration of the listed documents.

Respectfully submitted,

YOUNG & THOMPSON

BY:



Robert J. Patch, #17,344

745 South 23rd Street
Arlington, VA 22202
703-521-2297 (telephone)
703-685-0573 (telecopier I)
703-979-4709 (telecopier II)

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* English language abstract provided for the Examiner's convenience

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